

FORM PTO-1449  <b>LIST OF PATENTS AND PUBLICATIONS FOR APPLICANT'S INFORMATION DISCLOSURE STATEMENT</b>  (use several sheets if necessary)	SERIAL NO. <u>10/624930</u>	CASE NO. <u>9281/4596</u>
	FILING DATE <u>7/22/03</u>	Previously-Assigned GROUP ART UNIT <u>2627</u> <u>2652</u>
	APPLICANTS: SAITO et al.	

REFERENCE DESIGNATION U.S. PATENT DOCUMENTS

EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS/ SUBCLASS	FILING DATE
<i>Bm</i>	A1	5,287,238	02/15/1994	Baumgart et al.		
	A2	5,341,261	08/23/1994	Dieny et al.		
	A3	5,408,377	04/18/1995	Gurney et al.		
	A4	5,465,185	11/07/1995	Heim et al.		
	A5	5,549,978	08/1996	Iwasaki et al.		
	A6	5,552,949	09/1996	Hashimoto et al.		
	A7	5,576,915	11/1996	Akiyama et al.		
	A8	5,768,066	06/1998	Akiyama et al.		
	A9	5,583,725	12/10/1996	Coffey et al.		
	A10	5,598,308	01/28/1997	Dieny et al.		
	A11	5,701,223	12/23/1997	Fontana, Jr. et al.		
	A12	5,705,973	01/1998	Yuan et al.		
	A13	5,739,987	04/1998	Yuan et al.		
	A14	5,748,399	05/05/1998	Gill		
	A15	5,751,521	05/12/1998	Gill		
	A16	5,768,067	06/1998	Saito et al.		
	A17	5,768,069	06/16/1998	Mauri		
	A18	5,828,529	10/27/1998	Gill		
	A19	5,869,963	02/09/1999	Saito et al.		
	A20	5,871,622	02/16/1999	Pinarbasi		
	A21	5,880,913	03/09/1999	Gill		
	A22	5,910,344	06/08/1999	Hasegawa et al.		
	A23	5,949,622	09/1999	Kamiguchi et al.		
	A24	5,955,211	09/1999	Maeda et al.		
	A25	6,057,049	05/2000	Fuke et al.		
	A26	6,201,673	03/2001	Rotlmayer et al.		
	A27	6,157,525	12/2000	Iwasaki et al.		
<i>Bm</i>	A28	6,278,589	08/2001	Gill		

FOREIGN PATENT DOCUMENTS

EXAMINER INITIAL		DOCUMENT NUMBER	DATE	COUNTRY	CLASS/ SUBCLASS	TRANSLATION YES NO
<i>Bm</i>	A29	10-154618	06/09/1998	Japan		X
<i>Bm</i>	A30	10-91921	04/10/1998	Japan		X

EXAMINER <u><i>Bm</i></u>	DATE CONSIDERED <u>6/22/06</u>
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EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.